## IV

# Variable polarisation and other exotic Insertion Devices

#### Pascal ELLEAUME

European Synchrotron Radiation Facility, Grenoble

IV, 1/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Helical Undulator using Bifilar Helix



A bifilar Superconducting Helical Undulator was used In 1972 for the first FEL at HEPL, Stanford known since1950s Fixed Helicity

$$B_{\perp} = \frac{4\pi}{10\lambda_0} \left[ \left(\frac{2\pi a}{\lambda_0}\right) K_0 \left(\frac{2\pi a}{\lambda_0}\right) + K_1 \left(\frac{2\pi a}{\lambda_0}\right) \right]$$



Almost never used in synchrotron Sources :

- small horizontal aperture
- low field at room temperature
- no variation of polarisation

See L.R. Elias, J.M.J. Madey, Rev. Sci. Instrum. 50(11), Nov. 1979

IV, 2/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

- Beamline scientist are asking for variable polarization insertion devices which can produce :
  - Circular polarisation (left or right)
  - Linear polarisation (horiz, vertical, inclined)
  - Slow or fast switching of polarisation
  - High brilliance (=> preferably undulators)



IV, 4/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Two Orthogonal Permanent Magnet Planar Undulators

![](_page_4_Figure_1.jpeg)

Onuki, H., *Nucl. Instrum. Meth*. **A 246**, 94 (1986).

#### IV, 5/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

![](_page_5_Picture_0.jpeg)

IV, 6/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

### Electro-magnet Helical undulator (Ophelie at LURE)

![](_page_6_Picture_1.jpeg)

![](_page_6_Picture_2.jpeg)

IV, 7/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

#### **ESRF** Helios Type Undulator

![](_page_7_Figure_1.jpeg)

Vertical Field

- Simple to build & low magnetic forces
- Lower field than the Apple II
- Generates closed orbit distortion ~  $1/E^2$

IV, 8/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Apple II (Sasaki) Linear/helical Undulator

![](_page_8_Figure_1.jpeg)

Very popular :

- High magnetic field (at given period and gap)
- Generates any polarization (linear, elliptical,..)
- The field error correction is now mastered even though delicate

![](_page_8_Figure_6.jpeg)

![](_page_8_Picture_7.jpeg)

![](_page_9_Figure_0.jpeg)

$$\begin{bmatrix} B_{z}(0,0,s), B_{x}(0,0,s) \end{bmatrix} = \\ \begin{bmatrix} B_{z0} \cos(2\pi \frac{s}{\lambda_{0}} + \varphi_{2}), B_{x0} \cos(2\pi \frac{s}{\lambda_{0}} + \varphi_{2}) \end{bmatrix} + \\ \begin{bmatrix} B_{z0} \cos(2\pi \frac{s}{\lambda_{0}}), -B_{x0} \cos(2\pi \frac{s}{\lambda_{0}}) \end{bmatrix} + \\ \begin{bmatrix} B_{z0} \cos(2\pi \frac{s}{\lambda_{0}}), -B_{x0} \cos(2\pi \frac{s}{\lambda_{0}}) \end{bmatrix} + \\ \begin{bmatrix} B_{z0} \cos(2\pi \frac{s}{\lambda_{0}} + \varphi_{1}), B_{x0} \cos(2\pi \frac{s}{\lambda_{0}} + \varphi_{1}) \end{bmatrix} \end{bmatrix}$$

with  $B_{z0}, B_{x0}$  function of the magnetic gap

![](_page_9_Figure_3.jpeg)

#### IV, 10/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

![](_page_10_Figure_0.jpeg)

Antisymmetric Motion : 
$$\varphi_2 = -\varphi_1 = \varphi$$
  
 $[B_z(s), B_x(s)] = \left[ 4B_{z0} \cos^2(\frac{\varphi}{2}), -4B_{x0} \sin^2(\frac{\varphi}{2}) \right] \cos(2\pi \frac{s}{\lambda_0})$  : Linear  
 $\varphi = 0 \implies [B_z(s), B_x(s)] = [4B_{z0}, 0] \cos(2\pi \frac{s}{\lambda_0})$ : Vertical  
 $\varphi = \pi \implies [B_z(s), B_x(s)] = [0, -4B_{x0}] \cos(2\pi \frac{s}{\lambda_0})$ : Horizontal

IV, 11/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Radiation Pattern from Apple II

![](_page_11_Figure_1.jpeg)

#### 2<sup>nd</sup> Order Tune Shift of an Apple II at the ESRF

Horizontal Tune shift vary with phase => must be compensated on low energy rings

![](_page_12_Figure_2.jpeg)

## Apple II may reduce the dynamic aperture

![](_page_13_Figure_1.jpeg)

IV, 14/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Spring8 type Linear/Helical Undulator

![](_page_14_Figure_1.jpeg)

## Fast Switching electromagnet/permanent magnet helical undulator

![](_page_15_Figure_1.jpeg)

Field : 0.2 T Period : 80 mm Gap : 16 mm Current : 250 A Designed for 10 Hz flipping

#### Fast Switching by Electron Beam Deviations

![](_page_16_Figure_1.jpeg)

Induces perturbations to all other beamlines if not tuned precisely !

IV, 17/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

# Fast Switching using Chopper

![](_page_17_Figure_1.jpeg)

- No perturbation to the electron beam
- Requires very high quality optics
- Adequate only for low/medium energy ring (length of the bending magnets)

# Wiggler Sources of Circular Polarisation

- The radiation from wigglers is less brilliant than helical undulators but the only way to produce circularly polarized radiation at high energy.
- Based on the bending magnet radiation right (left) circularly polarized when observed below and above the orbit plane.
- Two types of devices are used
  - Asymmetric wigglers
  - Ellipsoidal wigglers

IV, 19/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Asymmetric Wiggler

![](_page_19_Figure_1.jpeg)

IV, 20/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Ellipsoidal Wiggler

![](_page_20_Picture_1.jpeg)

# Radiation from Ellipsoidal Wiggler

Period = 150 mm Kz = 8 Kx = 0.8

![](_page_21_Figure_2.jpeg)

IV, 22/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

### ELETTRA / SLS Helical Undulator/Wiggler

![](_page_22_Picture_1.jpeg)

IV, 23/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.

## Ellipsoidal Wiggler vs Asymmetric Wiggler

- An ellipsoidal wiggler has two source points per period (one for asymmetric wiggler).
- Ellipsoidal is used on-axis => no multiple source points.
- Radiation from ellipsoidal wigglers is used on a maximum of flux => less sensitivity to closed orbit distortion.
- An asymmetric wiggler is simpler mechanically but much more delicate magnetically => can generate large field integrals

IV, 24/31, P. Elleaume, CAS, Brunnen July 2-9, 2003.